





Welcome Message



On behalf of the organizing committee, it is my great honor and pleasure to cordially invite you to Korean International Semiconductor Conference on Manufacturing Technology 2022 (KISM 2022), which will be held at Busan, Korea from November 13 to 16, 2022.

KISM 2022 is the first international conference on semiconductors hosted by KSDT to commemorate the 20th anniversary, this meeting will be a fundamental ground to exchange high-quality results and ideas provided by the researchers and scientists within universities, industries, and research institutes. Furthermore, it also provides a conference to present the cutting-edge research outputs which would help both students and researchers with their future research studies and works to be conducted. Hence, the individuals actively engaged

in semiconductor manufacturing technology research and developments are greatly encouraged to participate in the conference and gain academic insights they have desired.

KISM 2022 will include prestigious Plenary Talks, Invited Talks, Regular Sessions (oral & poster presentations), and Exhibitions. I hope you take this unique opportunity to present your recent research and development highlights, interact with your colleagues and peers, and have a memorable and rewarding experience in KISM 2022.

I do thank you for your participation and contributions in advance and look forward to seeing you in Busan, Korea. Thank you very much.

Hyeongtag Jeon, Ph.D., Professor

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General Chair of KISM 2022 Division of Materials Science & Engineering College of Engineering Hanyang University

Abstract Submission
Deadline

2022.07.31. (Sun.)

Notification of Abstract Acceptance

2022.08.31. (Wed.)

Pre-Registration Deadline

2022.10.14. (Fri.)

Conference Topics

- 1. Nanoscale Thin Film Deposition
 Chair: Hyeongtag Jeon (Hanyang Univ., Korea)
- 2. CMP & Cleaning Chair: Jae-gun Park (Hanyang Univ., Korea)
- 3. High Functional Etching
 Chair: Geun Young Yeom (Sungkyunkwan Univ., Korea)
- **4. Advanced Lithography**Chair: Jinho Ahn (Hanyang Univ., Korea)
- **5. Heterogeneous Integration Package**Chair: Changhwan Choi (Hanyang Univ., Korea)
- 6. Nanoanalysis, Diagnosis and MI Chair: Tae-Hun Shim (Hanyang Univ., Korea)

